

9/2003 10/018,709

2. [ASI] - Default [ASI] Workspace ([Flat Panel LANDSCAPE].wsp; 1)

A screenshot of a software application window. The top menu bar includes File, Edit, View, Look, Window, and Help. A toolbar below the menu contains icons for Drafts, Pending, Active, Failed, Saved, Favorites, Tagged (0), UPC, Queue, and Trash. The main window features a search bar with fields for 'Search' (containing 'USA'), 'Browses' (containing 'USAFIRB'), 'Date' (containing '2011'), and 'Or'. Below the search bar is a 'Default operator' dropdown set to 'OR'. A list of items follows, starting with 'L1: (3) "Beauvoir JacquesS".in.' and including 'Saved', 'Favorites', 'Tagged (0)', 'UPC', 'Queue', and 'Trash'. On the right side of the main window, there are two checkboxes: 'Draft' (unchecked) and 'Highlight all items ready' (unchecked). The bottom status bar shows the path 'C:\Program Files\Aegisoft\Aegisoft Video Converter\Aegisoft Video Converter.exe'.

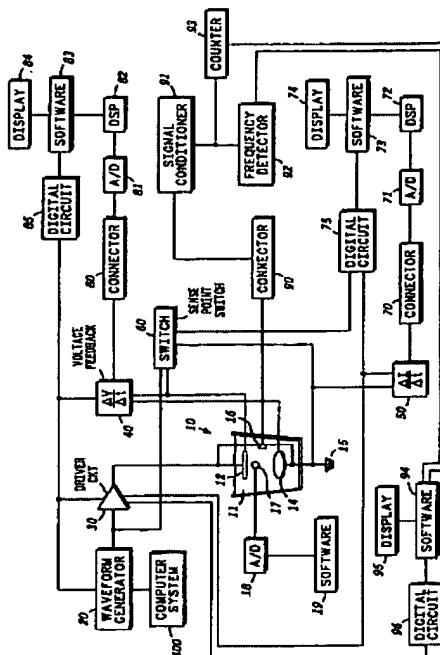
Patent Database Search Results										
	U	C1	PT	P	Document ID	Issue Date	Pages	Title	Current OR	Current Xref
	1	2	3	4	5	6	7	8	9	10
1	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 20020112962	20020822	10	Oxidising electrolytic method for obtaining a metal diaphragm for diaphragm-type valve	205/102	204/230.6
2	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 5201492 A	19930413			251/331	92/103M
3	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 4941504 A	19900717		Manual fluid-control valve with limited closing	137/524	137/556.3; 251/297;

9/2003 10/018,709

EASI - Detawlk EASI WorkSpace [File] Panel LANDSCAPE [WSB]

A screenshot of a software application window. The top menu bar includes File, New, Edit, Tools, Window, Help, and several icons. A toolbar below the menu contains icons for Drafts, Pending, Active, Favorites, Tagged (0), UDC, Queue, and Trash. On the left, a sidebar lists Drafts, Pending, Active, Favorites, Tagged (0), UDC, Queue, and Trash. The main area features a search bar with fields for 'Search' and 'Brows', and buttons for 'Clear', 'Queue', and 'Delete'. Below the search bar are fields for 'D1:' (US-EGGD) and 'Default operator' (OR). A list of items follows, each with a checkbox and a label: L1: (1471) (205/50-333) .CCLS., L2: (4611) waveform adj generator, and L3: (12) 11 and 12. At the bottom, there are sections for 'Saved' and 'Failed'.

	U	I	P	PT	P	Document ID	Issue Date	Pages	Title	Current OR	Current Xref	Retrieval C	Inventor	S	C	3
1	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 20020170826	20021121	7	Nickel electroforms	205/104	205/102		Wong, Kam Po et al.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
2	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 6620303 A1	20030916		Process for making nickel electroforms	205/67	205/104		Wong, Kam Po et al.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
3	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 6045681 A	20000404		Manufacturing method of planographic printing plate	205/214	204/DIG 9;		Mori, Takehiro	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
4	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 5605615 A	19970225		Method and apparatus for plating metals	205/83	205/172;		Goolsby, Peter G. et al.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
5	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 5486280 A	19960123		Process for applying control variables having fractal	205/67	204/229.7;		Bullock, IV, Jonathan S. et al.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
6	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 5470673 A	19951128		Electrochromic and electrocatalytic material	429/44	205/241;		Tseung, Alfred C. C. et al.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
7	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 5141602 A	19920825		High-productivity method and apparatus for making	205/103	205/115;		Chen, Chengjun J. et al.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
8	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 4789437 A	19881206		Pulse electroplating process	205/76	427/142;		Sing, Miu W. et al.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
9	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 4666567 A	19870519		Automated alternating polarity pulse electrolytic	205/83	205/104;		Loch, David M.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
10	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 4540376 A	19850910		Procedure for making nickel electrodes	205/60	204/DIG 9;		Dyer, Christopher K.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
11	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 4517059 A	19850514		Automated alternating polarity direct current	205/83	428/223		Loch, David M. et al.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>
12	<input checked="" type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>	US 4478869 A	19841023		Automated alternating polarity direct current	205/83	204/229.3;		Loch, David M.	<input type="checkbox"/>	<input type="checkbox"/>	<input type="checkbox"/>

Ready    |               |     |   |   |   |   |   |   |   |                      |               |
U.S. PATENT DOCUMENTS											
[51] Int. Cl. 6 C25D 5/18; C25D 5/50; C0IN 27/26											
[52] U.S. CL. 205/105; 205/106; 205/107; 205/108; 205/405; 204/434; 204/405; 204/406; 204/428											
[53] Field of Search 204/400, 228; 205/83; 103; 104; 105, 107; 108, 102, 106											
U.S. PATENT DOCUMENTS											
[54] 4,016,848 4/1977 Alton et al. .... 204/109											
[55] 4,065,374 12/1977 Alton et al. .... 204/228											
[56] 4,120,579 10/1978 Alton et al. .... 204/14 R											
[57] 4,461,080 7/1984 LaRiviere et al. .... 205/104											
[58] 5,156,729 10/1992 Mabrouk et al. .... 205/104											
FOREIGN PATENT DOCUMENTS											
1147356 3/1969 United Kingdom. 1524117 11/1978 United Kingdom.											
OTHER PUBLICATIONS											
Babcock et al. "Bipolar, Constant-Current, Electrocroplating Power Supply", Western Electric Technical Digest, No. 29 (Jan. 1973), pp. 5-6.											
[EAST] Document 1.3 (12) 1 and 2 (14) 5 Doc 3/12 (901FD1) F1m: 5 Doc: 3/12 (901FD1) F1m: KWIC											

US-PAT-NO: 5496280  
DOCUMENT-IDENTIFIER: US 5496280 A  
TIME: Process for applying control variables having fractal  
structures

**Detailed Description Text - DEX (4):**  
 With reference to FIG. 1, electroforming is achieved by placing the substrate 10 within an electrolytic solution 12. Current is passed between the electrode 14 and the electrode 10 to cause the deposition of components onto the substrate 10. The electrode 14 is connected to the electrolyte on the substrate 10, while the electrode 16 is connected to the Galvanostat 16 by a counter electrode connection 17, while the Galvanostat 16 by a working electrode connects to the substrate 10. The Galvanostat 16 is controlled by a waveform generator 20 which is in turn controlled by a microprocessor 18. The power required by the Galvanostat 16 is obtained from the power source 21, which for example can be 12VDC.

**Detailed Description Text - DTEX (6):**  
The fractal waveform is designed and, on command, is impressed as an input signal on a power amplifier, such as a galvanostat, such that a plating process can be driven by the power amplifier in a manner described herein. This is achieved by generating the design of the fractal waveform using a software program running on a personal computer, with output of the waveform to an arbitrary waveform generator, or by using a program located on a PROM chip housed in a waveform generator dedicated to electroforming in accordance with the present invention. In either case, the self-similar design of the waveform permits complete specification of a complex waveform with a relatively small number of parameters, each one being not arbitrary, but related to real physical properties of the plating system, especially

Detailed Description Text - DENTX (14) :

The specific legend items are defined as follows: t<sub>c</sub>.sub.0 is equal to the "amplitude clock" (time) interval and is included in the starting position at zero current with an artifact of waveform generator operation; t<sub>c</sub>.sub.1 is the length of the rectangular cathodic pulse, typically equal to t<sub>c</sub>.sub.0 and for most of the experiments performed was equal to 1 millisecond; t<sub>c</sub>.sub.2 is the time at zero current following the cathodic pulse, and is typically 4-9 times t<sub>c</sub>.sub.1; t<sub>c</sub>.sub.1 and t<sub>c</sub>.sub.2 taken together constitute the "cathodic pulse", which is repeated n<sub>c</sub>.sub.1 times; i<sub>c</sub>.sub.0 is the amplitude of the cathodic pulse measured in units of current; i<sub>c</sub>.sub.0 is the maximum amplitude of the anodic pulse in current units, is constrained to certain current values, and as a first approximation will be the same at all scales; C<sub>c</sub>.sub.0 is the number of coulombs per cathodic pulse and for a rectangular pulse is equal to the product of i<sub>c</sub>.sub.0 times t<sub>c</sub>.sub.1; and C<sub>c</sub>.sub.0 is the number of coulombs per anodic pulse associated with the shortest repeating period, while C<sub>c</sub>.sub.0, A<sub>c</sub>, C<sub>c</sub>.sub.0A<sub>c</sub>, etc., are associated with successively longer periods. After a train of n<sub>c</sub> cathodic pulses, each of length t<sub>c</sub>, which accumulate n<sub>c</sub> coulombs, an anodic pulse carrying f<sub>c</sub> coulombs is passed.

<b>United States Patent</b>	[19]	<b>Patent Number:</b>	<b>5,486,280</b>
Bullock, IV et al.		<b>Date of Patent:</b>	Jan. 23, 1996
<hr/>			
<b>PROCESS FOR APPLYING CONTROL VARIABLES HAVING FRACTAL STRUCTURES</b>	[19]	[11]	[45]
Inventor: Jonathan S. Bullock, IV, Oak Ridge; Roger L. Lawson, Oliver Springs, both of Tenn.	[75]	"Chaos", J. Gleick, Penguin Books, New York (1987). "Exploring the Geometry of Nature", B. Riemann, Windemere Books, Blue Ridge Summit, Pa. (1989). "Fractal Crayons", T. Wegner and M. Peterson, Walls Group Press, Mill Valley, Calif. (1991).	[45]
Assignee: Martin Marietta Energy Systems, Inc., Oak Ridge, Tenn.	[73]	"The Arrow of Time", P. Coveney and R. Highfield, Basic Books, New York (1990).	[45]
Appl. No.: 336,425	[21]	"Geometrical Forms Known as fractals find use in chaos", Smithsonian, Dec. 1983, pp. 110-117.	[45]
Filed: Oct. 20, 1994	[22]	"Practical Analysis of Zinc Electrodeposition", J. Electrochem. Soc. V. 137, No. 7, July 1990, pp. 2047-2051.	[45]
Int. Cl. <sup>6</sup>	[51]	"Researchers Find Order, Beauty in Chaos Chemical Systems", C&EN, Jan. 21, 1991, pp. 18-29.	[45]
U.S. Cl. _____	[52]	"Fractals Offer Mathematical Tool for Study of complex Chemical Systems", C&EN, Apr. 22, 1991, pp. 28-35.	[45]
Field of Search	[58]	"Beating a Fractal Drum", Science, Dec. 13, 1991, p. 1933.	[45]
		C5D 100	[45]
		205/67, 205/102, 205/103;	[45]
		205/104, 204/DIG. 9	[45]
		205/87, 102, 103,	[45]
		205/104, 204/DIG. 9	[45]

**Detailed Description Text - DEX (4):** With reference to FIG. 1, electroforming is achieved by placing a substrate 10 within an electrolytic solution 12. Current is passed between the substrate 10 and the electrode 14 to cause the deposition of components of the electrolyte on the substrate 10. The electrode 14 is connected to the galvanostat 16 by a counter electrode connection 17, while the substrate 10 is connected to the galvanostat 16 by a working electrode connection 19. The waveform of the current applied by the galvanostat 16 is controlled by a waveform generator 20 which is in turn controlled by a microprocessor 18, loaded with appropriate software. The power required by the galvanostat is

**Detailed Description Text - DTEX (6):**  
The fractal waveform is designed and, on command, is impressed as an input signal on a power amplifier, such as a galvanostat, such that a plating process can be driven by the power amplifier in a manner described herein. This is achieved by generating the design of the fractal waveform using a software program running on a personal computer, with output of the waveform to an arbitrary waveform generator, or by using a program located on a PROM chip housed in a waveform generator dedicated to electroforming in accordance with the present invention. In either case, the self-similar design of the waveform permits complete specification of a complex waveform with a relatively small number of parameters, each one being not arbitrary, but related to real physical properties of the plating system, especially

#### Detailed Description Text - DENTX (14):

The specific legend items are defined as follows: t<sub>c</sub>.sub.0 is equal to the "amplitude clock" (time) interval and is included in the starting position at zero current with an artifact of waveform generator operation; t<sub>c</sub>.sub.1 is the length of the rectangular cathodic pulse, typically equal to t<sub>c</sub>.sub.0 and for most of the experiments performed was equal to 1 millisecond; t<sub>c</sub>.sub.2 is the time at zero current following the cathodic pulse, and is typically 4-9 times t<sub>c</sub>.sub.1; t<sub>c</sub>.sub.1 and t<sub>c</sub>.sub.2 taken together constitute the "cathodic pulse", which is repeated n<sub>c</sub>.sub.1 times; i<sub>c</sub>.sub.0 is the amplitude of the cathodic pulse measured in units of current; i<sub>c</sub>.sub.0 is the maximum amplitude of the anodic pulse in current units, is constrained to certain current values, and as a first approximation will be the same at all scales; C<sub>c</sub>.sub.0 is the number of coulombs per cathodic pulse and for a rectangular pulse is equal to the product of i<sub>c</sub>.sub.0 times t<sub>c</sub>.sub.1; and C<sub>c</sub>.sub.0 is the number of coulombs per anodic pulse associated with the shortest repeating period, while C<sub>c</sub>.sub.0, A<sub>c</sub>, C<sub>c</sub>.sub.0A<sub>c</sub>, etc., are associated with successively longer periods. After a train of n<sub>c</sub> cathodic pulses, each of length t<sub>c</sub>, which accumulate n<sub>c</sub> coulombs, an anodic pulse carrying f<sub>c</sub> coulombs is passed.

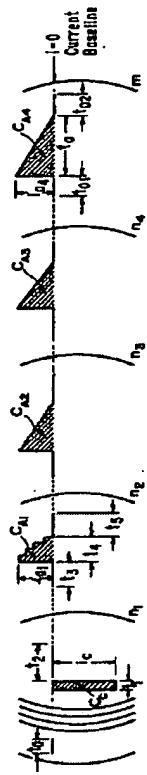
Hi EAST\_Devil EAST\_War  
[b] Document 7

EAST [Default EAST] Word [Document2 : Microsoft Word] EAST [Default EAST] Word [Document1 : Microsoft Word]

A vertical bar of icons typically found in the taskbar of a Windows operating system. The icons include: Microsoft Edge (internet browser), File Explorer (file manager), Microsoft Word (document editor), Microsoft Excel (spreadsheet editor), Microsoft Powerpoint (presentation editor), Microsoft OneNote (note-taking and productivity tool), Microsoft Outlook (email and calendar client), Microsoft Word (document editor), Microsoft Excel (spreadsheet editor), Microsoft Powerpoint (presentation editor), Microsoft OneNote (note-taking and productivity tool), Microsoft File Explorer (file manager), Microsoft Task View (task switching), and Microsoft Edge (internet browser).

ગુજરાત રાજ્ય વિદેશી વિષય

17 Claims, 2 Drawing Sheets



१८४ द्वितीय संस्करण

[57] **ABSTRACT** A process and apparatus for the application of a control variable having a fractal structure to a body or process. The process of the present invention comprises the steps of generating a control variable having a fractal structure and applying the control variable to a body or process reacting in accordance with the control variable. The process is applicable to electroforming where first, second and successive pulsed-currents are applied to cause the deposition of material onto a substrate such that the first pulsed-current, the second pulsed-current, and successive pulsed-currents form a fractal multi-current waveform.

ABSTRACT

ABSTRACT

[57] A process and apparatus variable having a fractal process of the present generating a control voltage applying the control voltage in accordance with the principles applicable to electrofor-  
mative pulsed-currents on material onto a substrate the second pulsed-current forming a fractal surface.

Document ID	D	V	Pages	1	2	3	4	5	U	S	C	P	Kind	Codes	Sort
1	US	6620303	B2	9											
2	US	6015681	A	25											
3	US	5605615	A	10											
4	US	5486280	A	7											
5	US	5470673	A	22											
6	US	5111602	A	37											
7	US	4769437	A	14											

US-PAT-NO:

5141602 A

DOCUMENT-IDENTIFIER:

TITLE: High-productivity method and apparatus for making  
customized interconnections

RMIC -----

## Detailed Description Text - DENX (39):

Electronic controller 88 comprises a microcomputer 101 with a data acquisition board 102, which controls an ac waveform generator 103, and an electrically controlled constant voltage or constant current amplifier 104. An ac ammeter 105 and an ac voltmeter 106, measures the voltage and the current on line 99.

## Detailed Description Text - DENX (40):

Acquisition board 102 couples a digital output signal indicative of frequency from digital output device 111 over lead 108 to an input of ac waveform generator 103. Acquisition board 102 couples a digital output signal indicative of amplifier mode (voltage or current) from digital output device 111 over lead 109 to an input of ac voltage/current power amplifier.

## Detailed Description Text - DENX (44):

In FIGS. 9A and 9B like references are used for functions corresponding to the apparatus of FIG. 8. The crystal oscillator 123, divide by four frequency divider 124 and programmable frequency divider 125 provide a stable source of frequencies between 1 KHz and 64 KHz. The frequency can be set by either the computer controller 121 or by switches. The voltage reference 131 accepts a voltage provided over lead 112 by the controller 121 or can generate a voltage set locally that varies between 1 mV and 10 V. The unity gain inverting amplifier 132 takes the reference voltage and generates a negative voltage of the same magnitude. The waveform generator 136 creates a square wave whose peak amplitude is equal to the output of the voltage reference 131 and whose frequency is set by the output of the programmable frequency divider 125. The square wave has an average value of 0 Volts. The voltage/current mode select circuit 137 determines whether the self induced repair is occurring in a constant voltage or constant current regime by the signals on lead 109. In the constant current mode the output from the waveform generator 136 is applied to the power amplifier 138. The constant current mode will be addressed later in this document. The power amplifier 138 is a unity gain amplifier capable of a peak output voltage of 10 Volts and a peak output current of 2.5 Amps. The current detector 139 senses the current delivered to the defect, line 99, and has an output voltage proportional to the current. This signal is precision full wave rectified by the full wave rectifier 145 and filtered by lowpass filter 147 to provide a voltage proportional to the average current through the defect. This average current is displayed on a digital voltmeter 149 as well as being fed back over lead 116 to the computer controller 121 and difference amplifier 143. In a similar manner, the voltage across the defect is passed through a full wave rectifier 146 and lowpass filter 148 to obtain a voltage equal to the average value of the defect voltage. This signal is displayed on digital voltmeter 150 and fed back to the computer controller 121.

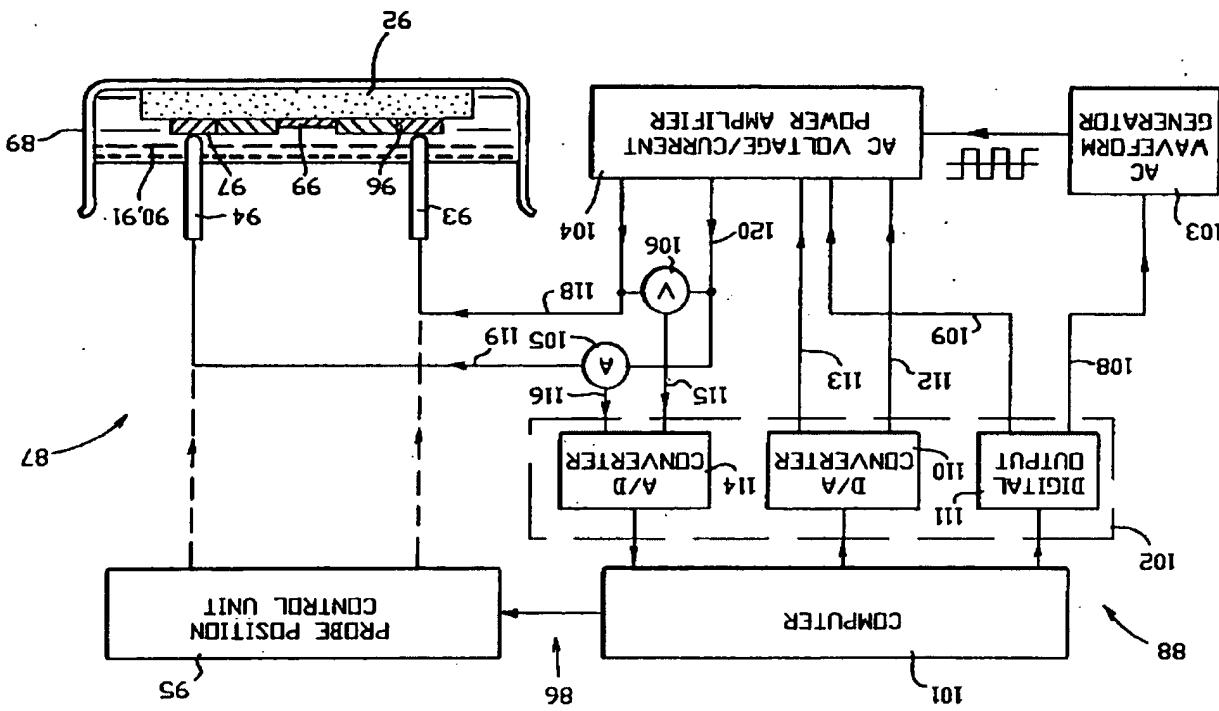


FIG. 8



US-PAT-NO: 5091152  
DOCUMENT-IDENTIFIER: US 5091152 A  
TITLE: Apparatus for electrically destroying targeted organisms in fluids

**Detailed Description Text - DETX (11):**  
A Waveform generator 6, and a current regulator 8 are provided. The outputs of the waveform generator 6 and the current regulator 8 are supplied to an amplifier 7.

**Detailed Description Text - DEX (12):** The Waveform Generator 6 is capable of providing a variable frequency output in a sine, square, pulsed negative-pulsed positive triggered, or saw-tooth waveform output 12, so that the targeted organism in inner area 33 and outer area 34, as shown in FIG. 2, can be destroyed.

**Detailed Description Text - DTEX (15):**  
As shown in FIG. 1B, a power supply 17 is provided which is capable of AC or DC operation, or in an uninterrupted configuration. The power output path to the waveform generator 6, the current regulator 8 and the power amplifier 7 are shown as 18.

**Detailed Description Text - DBTX (25):**  
 FIGS. 6A and 6B show a second embodiment of the present invention. In this embodiment, the power supply 17, waveform generator 6, current regulator 8, amplifier 7 and transformer 5 are configured as shown in FIG. 1, except that the output of the transformer 5 is connected to the chamber in a single ended output arrangement with the center tap (at 10 and 11) not used. This embodiment is for static sterilization purposes using a two electrode chamber.

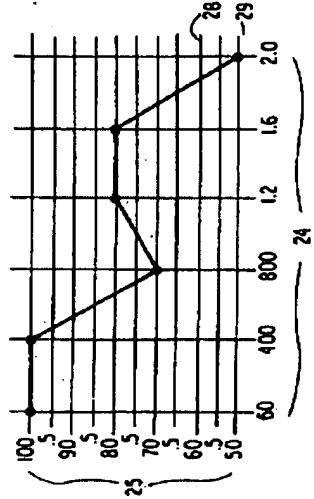
**Claims Text - CITEX (9):**  
A.C. current wavestorm generator means for generating a plurality of waveforms with variable frequency and magnitude.

**Claims Text - CLTX (11):** amplifier means, connected to receive the outputs of said waveform generator means and said current regulator means, for providing an amplified current;

**Claims Text - CLTX (12):** power supply means for supplying power to said waveform generator means, said current regulator means, said amplifier means and said transformer means;

claim text - CITA (14):

FIG. 4.



5  
Fig.

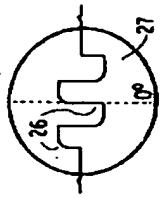


FIG. 64

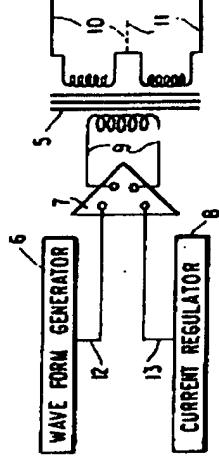
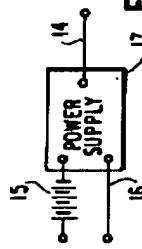


FIG 6B



ପ୍ରକାଶକ

EAST 87th | 89

ପ୍ରକାଶନ ମେଳିକା

9/2003 10/018,709

EAST - [Default EAST Workspace ([Flat Panel LANDSCAPE].wsp:1)]

A screenshot of a search interface, likely from a database or document management system. The top menu bar includes File, View, Edit, Tools, Window, Help, and several icons. A toolbar below the menu contains icons for search, browse, queue, and clear. On the left, there's a sidebar with Drafts, Pending, Active, and a search section for USPA/US-PGPUB. The main content area shows search results for the query "waveform or triangle". The results are listed as follows:

- L1: (14571) (205/50-333), CCUS.
- L2: (4611) waveform adj generator
- L3: (12) 11 and 12
- L4: (16883) (204/198-297.16), CCUS.
- L5: (15) 12 and 14
- L6: (11) 15 not 13
- L7: (187/378) triangular or triangle
- L8: (253/36) sawtooth or (saw adj tooth)
- L9: (207/945) 17 or 18
- L10: (45/1256) wave or waves or waveform or waveforms
- L11: (16/752) 19 near2 110
- L12: (59) 11 and 111

Below the results, there are links for Failed, Saved, Favorites, Tagged (0), WDC, Queue, and Trash.



9/2003 10/018,709

ZIFAS Document 112: [51] 1 and 11103-5705230X11ag.5 Doc: 10/30 (S07E01) Format: KWC

Document ID	V	Pages	1	3	U	S	C	P	Kind Codes	Search
13 US 5935408 A		7	□	□	□	□	□	□	USPAT	
14 US 5865978 A		21	□	□	□	□	□	□	USPAT	
15 US 5837121 A		7	□	□	□	□	□	□	USPAT	
16 US 5832834 A		11	□	□	□	□	□	□	USPAT	
17 US 5804400 A		16	□	□	□	□	□	□	USPAT	
18 US 5768819 A		48	□	□	□	□	□	□	USPAT	
19 US 5705230 A		5	□	□	□	□	□	□	USPAT	

DOCUMENT-IDENTIFIER: US 5705230 A

TITLE: Method for filling small holes or covering small recesses in the surface of substrates

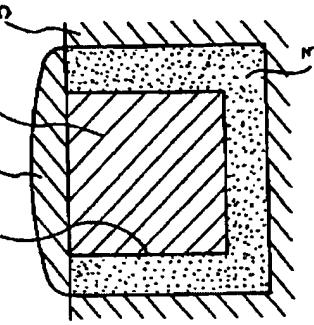
RMIC -----

## Detailed Description Text - DENTX (3):

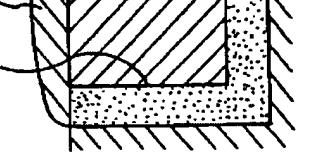
In the step of deposition, a controlled varying voltage and/or an energy such as low-frequency, high-frequency or ultrasonic vibrations or a light beam is preferably applied to the substrate. The applicable varying voltage includes voltages of pulsed waveforms such as square wave, trapezoidal wave, triangular wave, sinusoidal wave and random wave. The voltages of such pulsed waveforms may have both positive and negative polarities or they may have only negative polarity. The repetitive voltage components may be zero at periodic times; alternatively, a d.c. component may be added to a periodic wave. The value of the voltage to be applied is preferably such that a maximum absolute value of current density on the surface of the substrate is in the range of from  $10 \text{ A/cm}^2$  to  $1 \text{ A/cm}^2$ . The low-frequency, high-frequency or ultrasonic vibrations are preferably such that their frequency is in the range of from 45 Hz to 2.5 GHz.

Current US Cross Reference Classification - CCIR (1):  
205/109Current US Cross Reference Classification - CCIR (2):  
205/191Current US Cross Reference Classification - CCIR (3):  
205/191

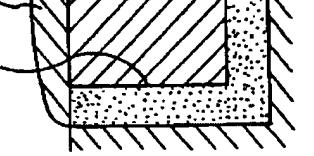
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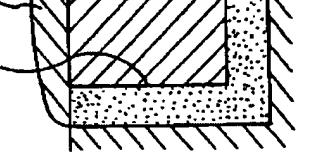
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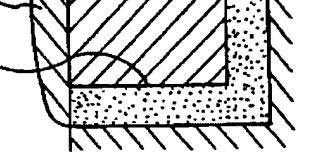
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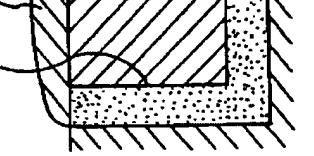
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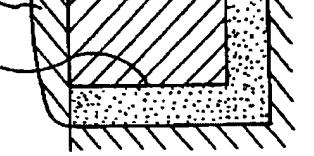
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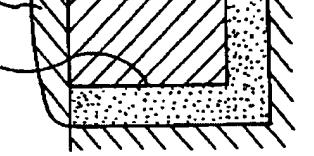
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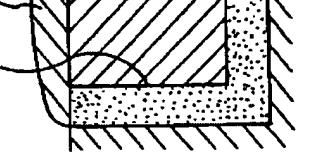
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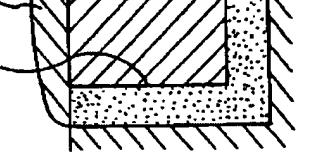
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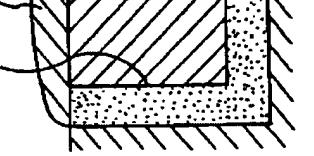
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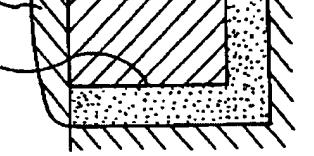
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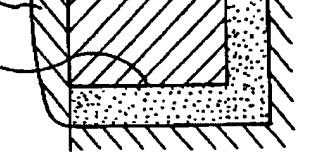
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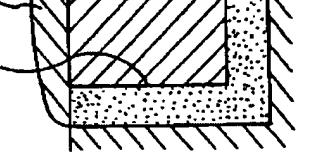
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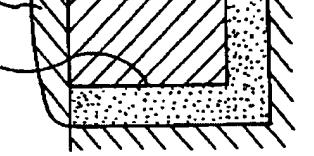
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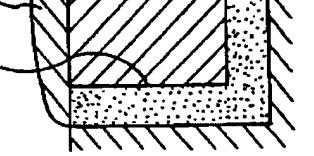
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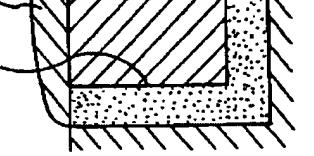
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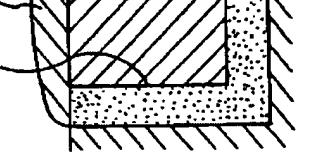
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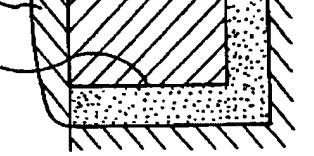
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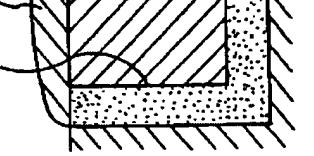
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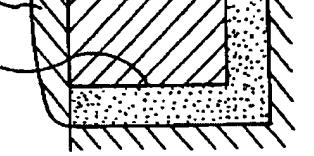
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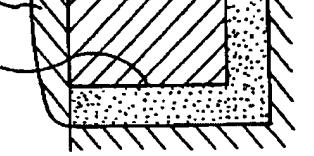
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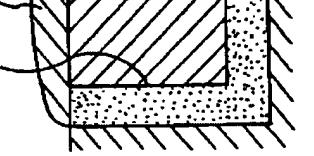
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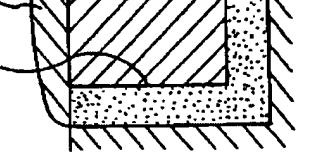
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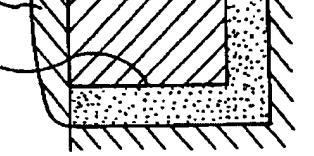
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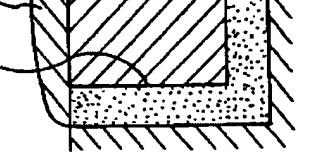
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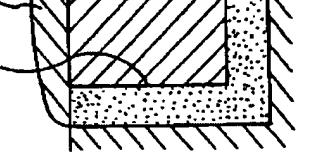
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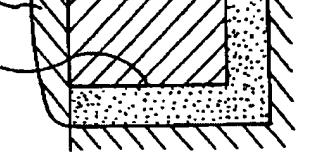
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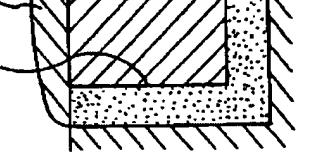
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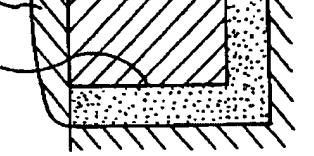
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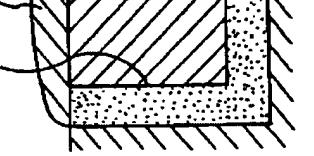
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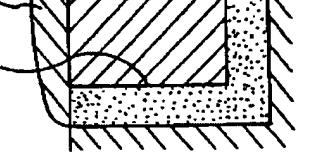
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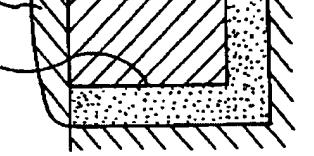
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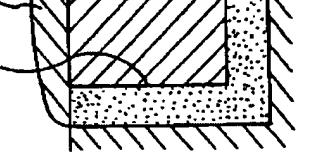
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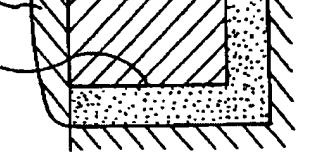
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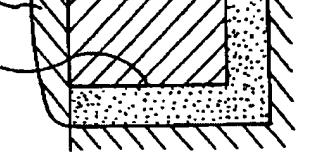
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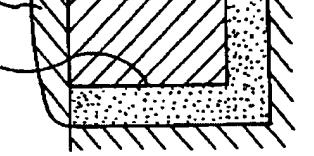
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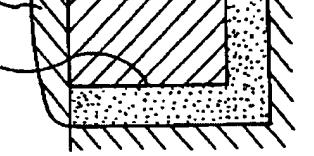
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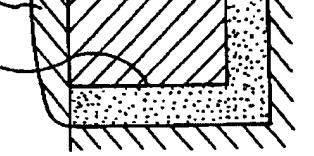
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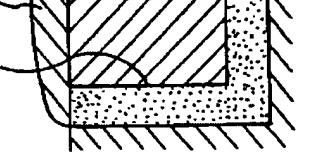
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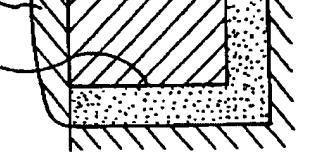
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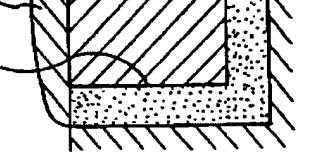
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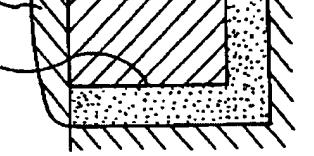
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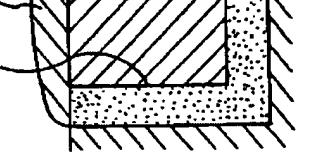
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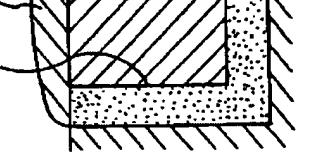
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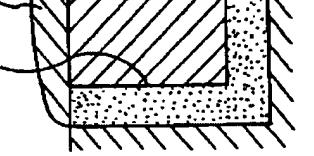
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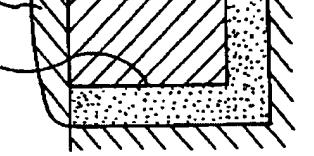
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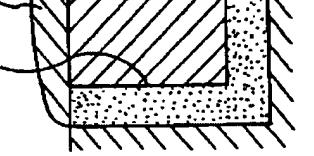
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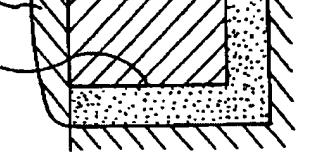
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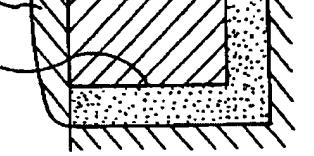
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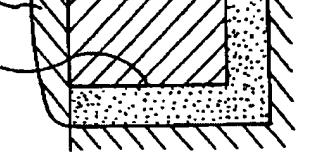
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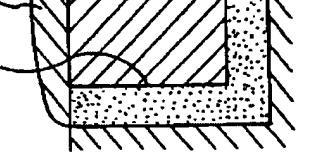
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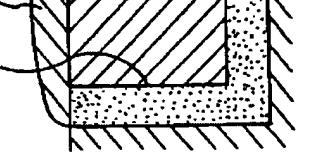
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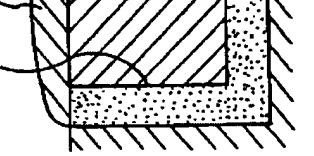
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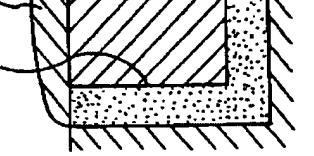
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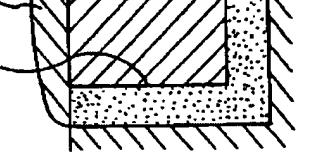
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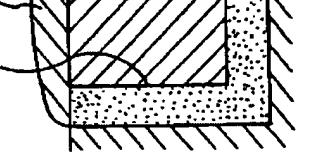
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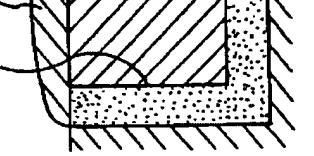
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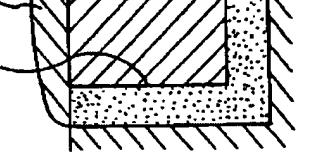
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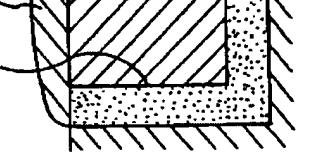
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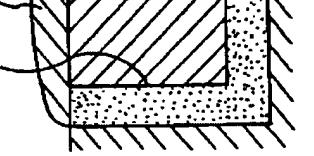
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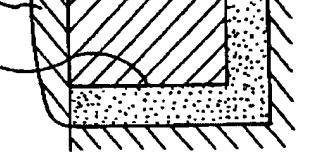
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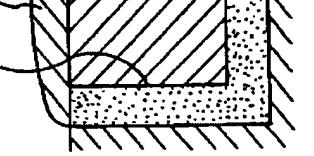
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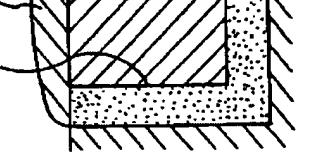
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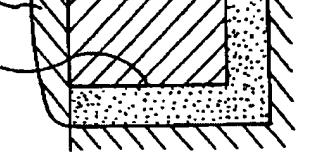
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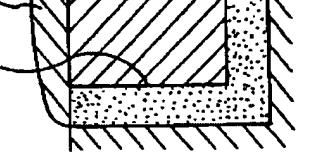
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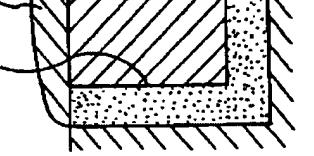
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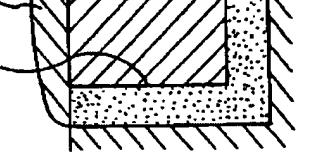
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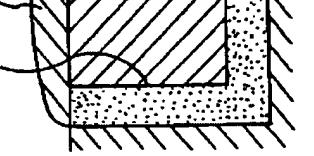
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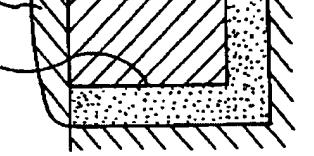
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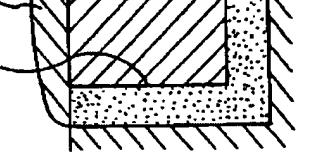
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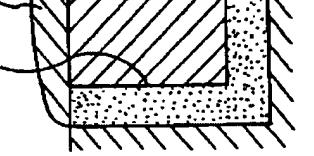
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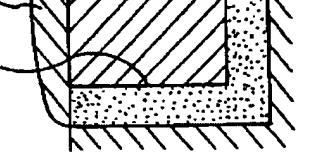
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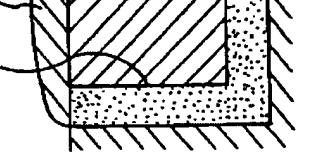
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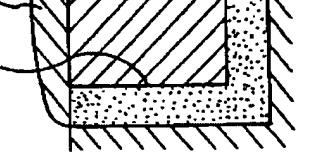
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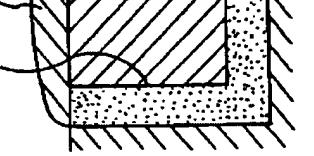
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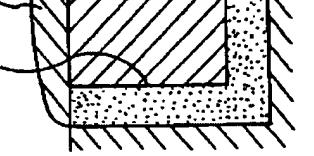
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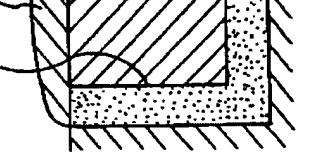
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DOCUME NTT - TD&NTT PAPER: 119 5364522 A

**TITLE:** Boride, carbide, nitride, oxynitride, and silicide infiltrated electrochemical ceramic films and coatings and the method of forming such

**Detailed Description Text - DENX (B):**  
A substrate subject to anodic coat polarized. A substrate subject to an external voltage relatively polarized. An external voltage applied to electrodes, a DC, or a pulsed DC, or triangular DC, or a stepped DC, and a electrodes and electrolytes.

**Detailed Description Text - DEX (9):**  
This invention relates that the preferred electric potentials or current waveforms consists of pure DC, a pulsed DC, a sine wave DC, a sawtooth DC, triangular DC, a stepped DC, a sine wave AC, and a mixture thereof.

**Detailed Description Text - DENTX (11):**  
When a pulsed DC voltage, or a sine triangular DC, or a stepped DC is applied different potentials to form a layered precursor composition with layered, lamellar sublattices are obtained by the modulating a multilayered coating can be obtained by the modulating densities at the proper waveform or pulse voltage or current density provides a precursor composition. The invention following an infiltration the multilayer coatings are infiltrated to multilayer having boride, carbide, nitride, oxyxynitride ceramic coatings with the maximum concentration gradients.

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10. A method as claimed in claim 7 wherein said amplitude-modulated electric current is an electric current with a constant or time-varied waveform selected from the group consisting of a single pulse, a multiple pulse, a sine wave, a sawtooth, a triangular, a stepped shape, a convolution of different geometric shapes, and a mixture thereof.

United States Patent	[19]	[11]	Patent Number:	5,364,522
Wang		[45]	Date of Patent:	Nov. 15, 1994
[54] BORIDE, CARBIDE, NITRIDE, OXINITRIDE, AND SILICIDE INFILTRATED ELECTROCHEMICAL CERAMIC FILMS AND COATINGS AND THE METHOD OF FORMING SUCH	[76] Inventor: Liang Wang, 5129 Maddox Rd., Tallahassee, Fla. 32303	Chemical Abstracts, vol. 89, p. 338, Abs. #13763c. Chemical Abstracts, vol. 93, p. 256, Abs. #119035g. Science, 1992, 258, 1918-1921. J. Electrochem. Soc., 1991, 138, 1038-1040. Electrochim. Acta, 1992, 37, 2421-2426. Nature, 1992, 357, 395-397. J. Electrochem. Soc., 1991, 138, 1643-1645. J. Electrochem. Soc., 1992, 139, 67-69. J. Electrochem. Soc., 1980, 127, 2053-2057. Chem. Abstracts, vol. 97-Ceramics, p. 265; Abst. 190566g.		
[21] Appl. No.: 35,424	[22] Filed: Mar. 22, 1993	Primary Examiner—Kathryn Georges		
[51] Int. Cl. 4	[52] Int. Cl. 4	ABSTRACT		
[54] C25D 5/20; C25D 3/02	[52] C25D 5/20; C25D 3/02	Ceramic films and coatings, single or multi-layered, including superlattice, infiltrated with boride, carbide, nitride, oxynitride, and silicide were formed by methods which comprises an electrochemical coating of a ceramic precursor by a constant or an amplitude-modulated electric current with a DC component in a medium containing at least one of the ionic species for the composition of the ceramic precursor, following single or multiple infiltration in a medium containing at least one of the compounds selected from a B-containing compound, a C-containing compound, a N-containing compound, a Si-containing compound, and a mixture thereof, by heating means selected from radiofrequency, microwave, thermal, flame, plasma, laser, and a mixture thereof.	[57]	
[36] Field of Search: 205/224, 205/118, 205/7229, 206/162; 208/174; 208/316; 428/446; 428/659; 428/685; 428/698; 428/704; 205/59, 106, 108, 224; 205/229, 118, 174, 316, 162; 428/446, 689, 688, 698, 702				
[56] References Cited				
U.S. PATENT DOCUMENTS				
4,882,014 2/1988 Coyle	204/7.5			
FOREIGN PATENT DOCUMENTS				
0046715 12/1981 European Pat. Off. .... 204/316				
OTHER PUBLICATIONS				
Chemical Abstracts, vol. 94, p. 187, Abs. #124792p. Chemical Abstracts, vol. 66, p. 1089, Abs. #10398a. Chemical Abstracts, vol. 105, p. 292, Abs. #119373r.	24 Claims, No Drawings			

**Claims Text - CIIIX (20):**  
20. A method as claimed in claim 16 wherein said amplitude-modulated electric current is an electric current with a constant or time-varied waveform selected from the group consisting of a single pulse, a multipulse waveform.



United States Patent [19]									
Hanagata et al.									
[54] Patent Number: 5,147,515 [11] Date of Patent: Sep. 15, 1992									
US505147515A									
Document ID	V	Pages	1	2	3	4	5	6	7
23	US 5384215 A	15	<input type="checkbox"/>						
24	US 5364322 A	9	<input type="checkbox"/>						
25	US 5320719 A	10	<input type="checkbox"/>						
26	US 5268235 A	10	<input type="checkbox"/>						
27	US 5171116 A	8	<input type="checkbox"/>						
28	US 5158853 A	9	<input type="checkbox"/>						
29	US 5147515 A	8	<input type="checkbox"/>						
[51] Primary Examiner—John N. Nigl Assistant Examiner—Brian M. Bohan Attorney, Agent or Firm—Ohion, Spivak, McClelland, Maler & Neustadt									
[52] ABSTRACT									
A method for forming a ceramics film on the surface of a substrate comprises performing spark discharge in an electrolytic bath, wherein the electrolytic bath comprises an aqueous solution of a water-soluble or colloidal silicate and/or an oxyacid salt to which ceramics fine particles and/or specific fine particles are dispersed and the spark discharge is carried out in the electrolytic bath while suspending the suspended state of the ceramics particles and/or the specific fine particles in this electrolytic bath. The method makes it possible to effectively form, on the surface of a metal substrate, ceramics films having a variety of color tones as well as excellent insulating properties and hardness. Moreover, it further makes it possible to effectively form a composite ceramics film having excellent wear resistance on the surface of a metal substrate.									
[53] Claims, No Drawing									
[57]									
DOCUMENT-IDENTIFIER: US 5147515 A									
TITLE: Method for forming ceramic films by anode-spark discharge									
RWIC -----									
Brief Summary Text - BSTX (31): The output from a power supply may be a direct current having any wave form, but preferably those having pulse shape (rectangular wave form), saw-tooth wave form or DC half-wave form.									
Current US Cross Reference Classification - CCXR (1): <u>205/320</u>									
Current US Cross Reference Classification - CCXR (2): <u>205/321</u>									
Current US Cross Reference Classification - CCXR (3): <u>205/322</u>									
Current US Cross Reference Classification - CCXR (4): <u>205/323</u>									
[50] Foreign Application Priority Data									
Sep. 4, 1989 [JP] Japan 1-3286319 Mar. 6, 1990 [JP] Japan 2-54827									
[51] Int. Cl. H05F 9/04									
[52] U.S. Cl. 204/164; 205/320; 205/321; 205/322; 427/37									
[58] Field of Search 204/164; 205/322; 427/37; 204/166; 427/37; 204/461; 58; 58A; 204/626; 63; 63/26-22; 205/321; 322; 323; 320									
[56] References Cited									
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3,812,021 5/1974 Chig et al. 204/164									
3,812,021 5/1974 Rogen et al. 204/164									
3,822,293 8/1974 Hradcovy et al. 204/164									
3,936,080 5/1976 Hradcovy et al. 204/164									

US-PAT-NO:	4923574
DOCUMENT-IDENTIFIER:	US 4923574 A
TITLE:	Method for making a record member with a metallic anti-friction overcoat

----- RWIC -----

Drawing Description Text - DRWX (8):

FIG. 7 shows a triangular or swept waveform for applied current density as a function of time.

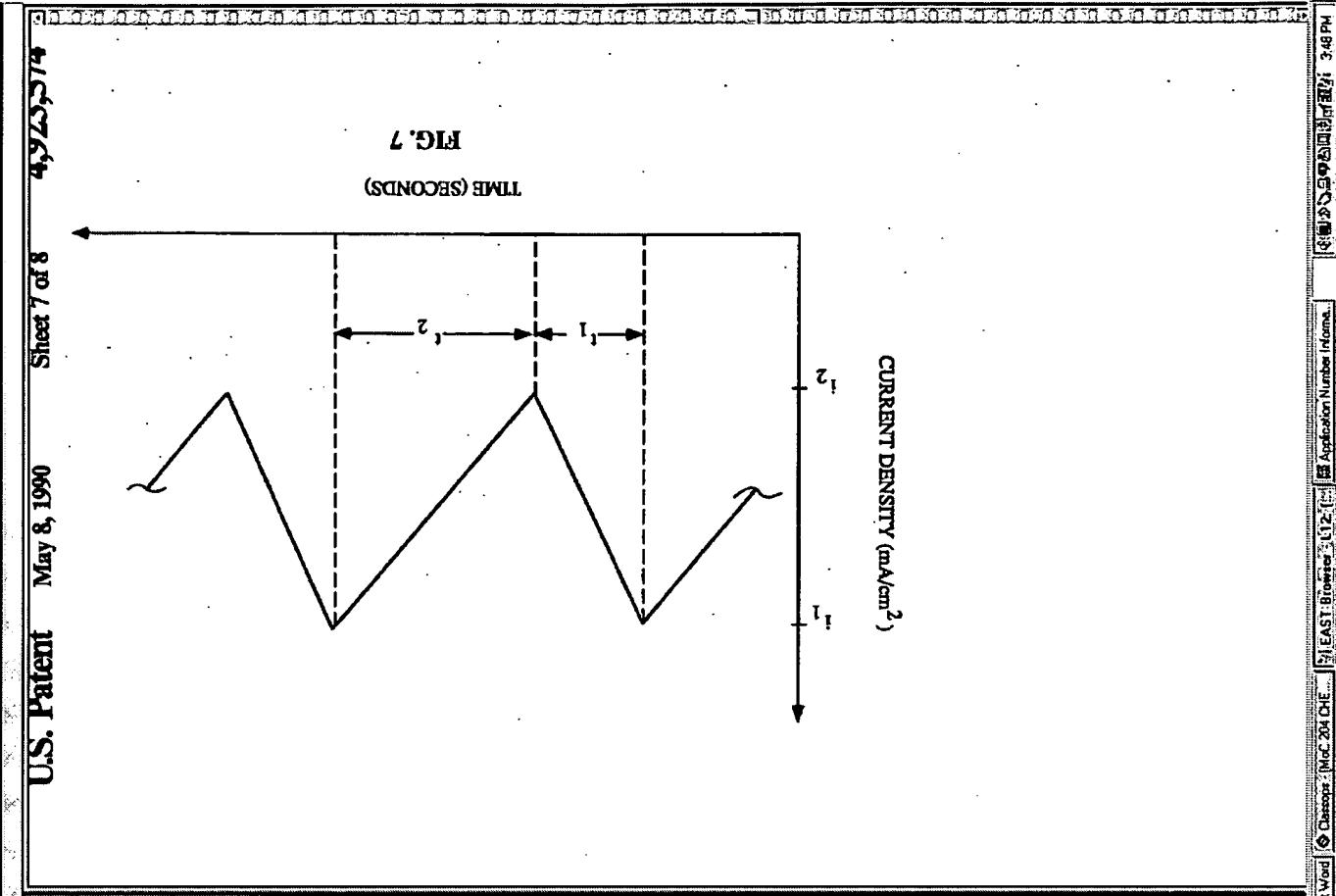
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Detailed Description Text - DRWX (43):

It should be noted that the duration of the high or low values of current density as illustrated by the waveform shown in FIG. 5 can be varied and controlled by the function generator to achieve desired thicknesses of the layers 11, 12, 13, 14. The thickness of each layer is directly related to the amount of electric charge utilized during its electrodeposition. Thus, for a given current density, the thickness of a layer is controlled by the time the current is applied to the electrolytic cell. The composition of the plated alloy can be varied and controlled by changing the current density (or cathode potential) to a value which gives the desired composition. FIG. 7 provides another example of a graph of a current density versus time which may be used to generate another layered structure. A similar waveform may be applied to the cathode potential. The result of the use of this triangular or swept waveform is a triangular or graded variation in the composition of the alloy layers plated.

Detailed Description Text - DRWX (44):

FIGS. 5 and 7 are merely examples of the many waveforms which may be employed in order to form a layered structure. Other alternative embodiments of the present invention include electrodepositing more than two layers per cycle. This is accomplished by creating a series of different current densities or cathode potentials before repeating the cycle. Thus, it can be seen that the method of this invention permits the design of a resulting plated structure by variation of the magnitude of the current or cathode potential applied and the duration that a given current density or cathode potential is applied. In particular, the waveform shown in FIG. 8 may be used to produce four layers per cycle: a first layer of graded composition during time period t<sub>sub.1</sub>; a second layer of constant composition during time period t<sub>sub.2</sub>; a third layer of graded composition during time period t<sub>sub.3</sub>; and a fourth layer of constant composition during time period t<sub>sub.4</sub>. Similarly, other combinations of stepped, triangular, and sine waveforms may also be utilized.



	Document ID	V	Pages	S	U	C	P	Kiran's Grades	Score
40	US_4679018_A		5	□	□	□	□	□	USPAT
41	US_4114529_A		6	□	□	□	□	□	USPAT
42	US_4104156_A		7	□	□	□	□	□	USPAT
43	US_4656411_A		18	□	□	□	□	□	USPAT
44	US_4526659_A		7	□	□	□	□	□	USPAT
45	US_4490218_A		7	□	□	□	□	□	USPAT
46	US_4468233_A		11	□	□	□	□	□	USPAT

US-PAT-NO: 4468293  
DOCUMENT-IDENTIFIER: US 4468293 A  
TITLE: Electrochemical treatment of copper for improving its bond strength

**Brief Summary Text - Bxg (20):**  
 More particularly, an electrolytic bath comprising a copper sulfate-sulfuric acid solution is maintained in an electrochemical cell. The cell has an anode and a cathode. The cathode comprises the copper sheet or foil upon which the dendrites are to be deposited. Current is applied across the cell either by a constant current source and a function generator or a constant voltage source and a function generator. The applied current preferably has a suitable wave form, such as a square wave, a triangular wave, a sinusoidal wave, etc. The applied current causes clusters of copper particles to be deposited on and bonded to the copper sheet or foil. These clusters of copper particles from the dendrites. They generally have a relatively fine structure which is highly desirable. It is believed that the relatively fine dendritic structure is a result of the initiation of many nucleation sites during an initial current pulse and the re nucleation of the dendritic structures each time there is another current pulse. In addition, undesirable columnar structures are avoided by not exposing the dendritic structures to relatively long periods of time at current densities above the limiting current density. After the sheet or foil has been treated in accordance with the instant invention, it may be laminated to a non-metallic substrate so as to form, for example, a printed circuit board.

**Detailed Description Text - DEX (B):**  
 The current applying system 15 preferably comprises a constant d-c current source 18 and a function generator 20. The function generator 20 provides the current applied to the cell 10 with a desired waveform. The current applied to the cell 10 is preferably an uninterrupted, multi-cycle, fluctuating current having a cathodic portion with first and second current densities each with a magnitude greater than zero and flowing in only one direction. As shown in FIGS. 2-4, the applied current is a non-zero base cathodic current in which the second current density is also the base current density. Any suitable current waveform, such as the square waveform shown on FIG. 2, the triangular waveform shown in FIG. 3, and the sinusoidal waveform shown in FIG. 4 may be used as long as it has a cathodic portion with first and second current densities having a magnitude greater than zero. The constant current source 18 and the function generator 20 may comprise, respectively, any conventional constant current source and function generator as are known in the art.

**Detailed Description Text - DEMX (17):**  
 The voltage applied to the cell 10, may have any suitable waveform such as a square waveform, a triangular waveform, a sinusoidal waveform, etc. Constant voltage source 28 and function generator 30 may comprise any conventional constant voltage source and function generator as are known in the art. The voltage control system 25 will obtain substantially the same result as the

U.S. Patent Aug. 28, 1984 Sheet 1 of 3 4,468,293

Sheet 1 of 8

U.S. Patent Aug. 28, 1984

4468293

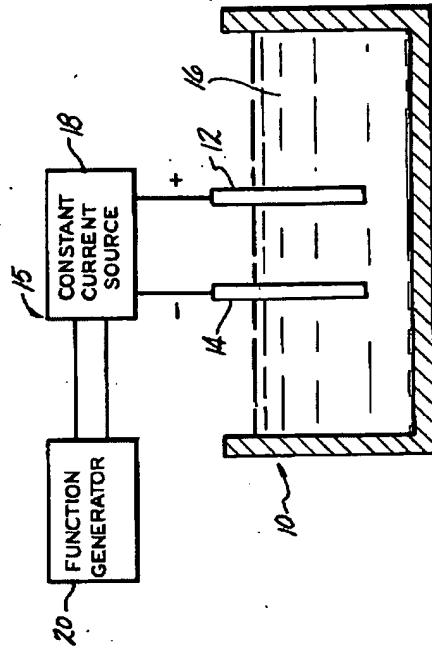


FIG - I

FIG-2

A graph illustrating two different current waveforms over time. The vertical axis is labeled "TIME".

- The left waveform, labeled "I" at its baseline, is a sawtooth wave. It starts at a high level, drops sharply in a straight line to a lower level, and then remains constant until the next sharp drop.
- The right waveform, also labeled "I" at its baseline, is a smooth sine wave. It oscillates sinusoidally between two levels.

TIME

FIG-4

JESTI Database (JESTI Workshare [Flat Panel LANDSCAPE].wsp.1)

File Edit Tools Window Help

Drafts

Pending

Active

L1: (14571) (205/50-333) .CCLS.

L2: (4611) waveform adj generator

L3: (12) 11 and 12

L4: (16683) (204/198-297.16) .CCLS.

L5: (15) 12 and 14

L6: (11) 15 not 13

L7: (187378) triangular or triangle

L8: (25336) sawtooth or (saw adj tooth)

L9: (207945) 17 or 18

L10: (451256) wave or waves or waveform or waveforms

L11: (16752) 19 near2 110

L12: (59) 11 and 111

L13: (122) ((205/173) or (205/174)) .CCLS.

Failed

Saved

Favorites

Tagged (0)

UDC

Queue

Trash

Search [ ] List [ ] Browse [ ] Queue [ ] Clear [ ]

Do: [ ] USPA: US PGPUB

Highlight full term only [ ]

205/173  
205/174

ISAK term [ ] ISAK term [ ] Text [ ] HTML [ ]

U	P	R	T	P	Document ID	Issue Date	Pages	Title	Current OR	Current Xref	Retrieval C	Inventor	S	C	3	
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Ready

File Start

Help Microsoft Outlook

Exploring - C:\

JESTI - Default EAST

Document2 - Microsoft Word

Classmate - MFC 204 CHE

Application Number Search

9/2003 10/018,709 3:58 PM



9/2003 10/018,709

EASI - Detainee Welfare Panel (LandScape) [wpd]:1

The screenshot displays the EAST software interface, which includes a left sidebar for navigation and a main search results area.

**Left Sidebar:**

- File: New, Edit, Lock, Window, Help
- Drafts
- Pending
- Active
  - L2: (14571) (205/50-333).CCIS.
  - L3: (25336) sawtooth or (saw adj tooth)
  - L4: (160571) waveform or waveforms
  - L5: (30528) (wave adj form) or (wave adj forms)
  - L6: (178481) 14 or 15
  - L7: (6944) 13 same 16
  - L8: (16) 12 and 17
- Failed
- Saved
- Favorites
- Tagged (0)
- UDC
- Queue
- Trash

**Main Area:**

Search: USA/US/PUB  
OR  
Default operator: OR  
DB:  
Search [List] [Browse] [Queue] [Clear]

Highlight all terms today

Results:

Title	Current OR	Current Xref	Retrieval C	Inventor	S	C	S	C	I

Actions: Add item [Image] [Text] [HTML]

Ready: Start [ ] Stop [ ] Hold [ ] Micro... [ ] Easing... C1 [ ] Open... N [ ] Append... N [ ] 100x103mm [ ] New case file [ ] 100x103mm [ ] 100x103mm [ ] 100x103mm [ ] EAST [ ] Ready



9/2003 10/018,709

**EAST : Detainees** [At Panel 1 AND SCAPE] were 11

The screenshot shows a digital library application with a search interface and a list of search results.

**Search Interface:**

- Search Fields:** Title, Author, Subject, Date, Call Number, Item Type, Status.
- Search Operators:** AND, OR, NOT.
- Search Buttons:** Search, Advanced Search, Help.
- Checkboxes:** Drafts, Pending, Active, Drafts, Pending, Active.
- Checkboxes (Top Right):** Publish, Highlight all hit terms initially.
- Text Input:** USA, IS, FR, GB.
- Text Input (Bottom Left):** OR.
- Text Input (Bottom Center):** 112 not 18.

**Search Results List:**

- L2: (14571) (205/50-333).CC11S.
- L3: (25336) sawtooth or (saw adj tooth)
- L4: (160571) waveform or waveforms
- L5: (30528) (wave adj form) or (wave adj forms)
- L6: (178481) 14 or 15
- L7: (6944) 13 same 16
- L8: (16) 12 and 17
- L9: (28957) ("205").CLAS.
- L10: (45731) ("204").CLAS.
- L11: (64358) 19 or 110
- L12: (81) 111 and 17
- L13: (65) 112 not 18

**Action Buttons:**

- Failed
- Saved
- Favorites
- Tagged (0)
- UDC
- Queue
- Trash





9/2003 10/018,709

[3] EAST - Default EAST Workspace [Flat Panel LANDSCAPE].wsp [1]

A screenshot of a software application window. At the top, there's a menu bar with File, Edit, Tools, Window, and Help. Below the menu is a toolbar with icons for Drafts, Pending, Active, Search, List, Browse, Delete, Date, DB+, ISPA+, USPUB, Default Operator, DR+, and Block. There are also checkboxes for 'Highlight struck terms' and 'Block'. The main area contains a list of search results. Each result is a numbered line (L1-L14) followed by a list of terms in parentheses. Some lines have a small icon to their left. To the right of the list is a vertical scroll bar. At the bottom, there's another toolbar with icons for Failed, Saved, Favorites, Trashed (0), Queue, and Trash.

- L1: (362) (205/123).CCLS.
- L2: (145/455) triangular
- L3: (1.60571) waveform or waveforms
- L4: (30528) (wave adj form) or (wave adj forms)
- L5: (178481) 13 or 14
- L6: (6263) 12 same 15
- L7: (0) 11 and 16
- L8: (5) 11 and 12
- L9: (14571) (205/50-333).CCLS.
- L10: (35) 19 and 16
- L11: (329350) generator
- L12: (4873) 15 adj 111
- L13: (429) 112 same 12
- L14: (1) 113 and 19

U	I	P	T	Document ID	Issue Date	Title	Current OR	Current XRef Retrieval C	Inventor
1	□	□	□	US 6334945 B1	20020101	Aging process for solid electrode capacitor	205/687	205/229; 205/688;	Lessner, Philip Michael et al.

Document ID	V	Pages	1	2	3	U	S	C	P	Kind Codes	Search
4 US 5837121 A		7	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	USPAT	
5 US 5516229 A		8	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	USPAT	
6 US 5364522 A		9	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	USPAT	
7 US 5147515 A		8	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	USPAT	
8 US 5111602 A		27	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	USPAT	
9 US 4879018 A		5	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	USPAT	
10 US 4656411 A		18	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	[ ]	USPAT	

US-PAT-NO: 4656411  
DOCUMENT-IDENTIFIER: US 4656411 A

TITLE: DC current controller for hydroset battery electrode  
electroformation

----- XMIC -----

Detailed Description Text - DENTX (6):

Following the signal flow from the regulator block 23 in FIG. 1, to the next functional block of FIG. 1, that is, the PWM duty cycle generator 24 (FIG. 1)... The common approach to build a duty cycle generator is to form a saw tooth wave (triangular) and vary a reference over the slope of the saw tooth wave form.

Detailed Description Text - DENTX (9):

Considering the large and non-linear changes that can take place, a new approach had to be conceived that is cost effective and simple. The circuit that fits into the PWM duty cycle generator block 24 shown in FIG. 1 is detailed by Q1, Q2, Q3, and IC2 shown in FIG. 4 and their related components. This circuit has a fixed reference and the saw tooth varies in amplitude, but the saw tooth is actually trapezoidal with an adjustable slope. The slope is the important factor that makes the circuit respond to the large changes in load and circuit impedances. FIGS. 8A-8D shows the wave form that is developed by the circuit in block 24 and has the variable slope adjustment capability.

Detailed Description Text - DENTX (10):

VR is the reference voltage that is constant and set by the voltage divider resistors R14 and R15 and is one input to the non inverting input IC2. NPN transistor Q1, R8, R9, R10 and R11 form a linear amplifier with fast response from a signal input from IC1. PNP transistor Q2, R12, C9 and R13 form a controlled charge rate circuit to form the slope and sides of the trapezoid controlled by the input of Q1. If R13=0 OHMS the wave form would be saw tooth or triangular. Increasing the OHMIC value of R13 flattens the slope for a faster response. The combination of a fast Q1 amplifier to an IC1 input and the correct slope fixed by R13 makes the PWM regulate better than +/-2% on load current. IC2 (FIG. 4) is the voltage comparator that compares the reference VR to the crossing points on trapezoidal wave form as shown in FIGS. 8A-8D. IC2 finds the crossing points and outputs the square wave. NPN transistor Q3 is a reset switch controlled by signal pulses from the oscillator 26. The frequency of the oscillator 26 determines the switch rate period "T" and the input from IC1 determines the voltage height of the trapezoidal wave form of time on and time off of period "T". C5 is a positive feed back capacitor of several hundred picofarads that increases the slew rate of the operational amplifier IC2 that squares the output wave form.

Current US Cross Reference Classification - CCXR (1):

205/63

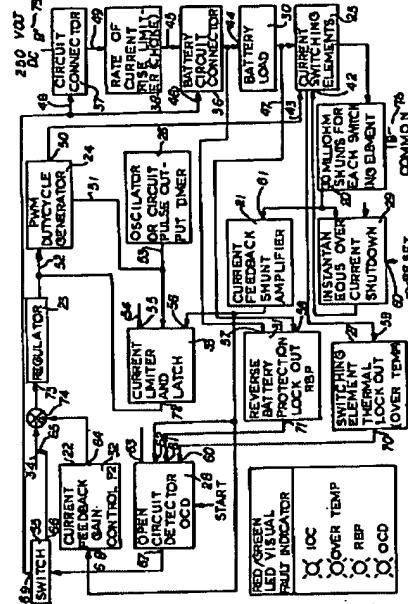
United States Patent [1]		[1] Patent Number: 4,656,411	
Carlson		[45] Date of Patent:	Apr. 7, 1987
[54] DC CURRENT CONTROLLER FOR HYDROSET BATTERY ELECTRODE ELECTROFORMATION		4,613,078 1/1982 Bliley et al.	320/15
		4,312,222 5/1983 Kurs et al.	320/61
		4,312,222 5/1983 Gupta et al.	327/50 X
		4,431,371 2/1984 Newman	327/40 X
		4,441,372 4/1984 Rubin	320/18 X
		4,467,655 8/1984 Pashok	320/21
		4,474,572 9/1984 Smith	320/40 X
		4,486,302 9/1984 Smith	320/40 X
		4,567,421 1/1986 Daniels	320/40 X

Primary Examiner—W. B. Perkey Attorney, Agent, or Firm—Charles L. Lovercheck, Wayne L. Lovercheck, Dale R. Lovercheck

### ABSTRACT

A closed loop regulating system suitable for battery plate formation is provided. The circuit incorporates MOS FET and provides compensation for resistance changes that occur in MOS FET devices due to temperature changes. The regulating system also has means to precisely compensate for substantial impedance changes that occur over long time periods of an electroforming cycle for both of various times.

### 37 Drawing Figures



37 Claims, 16 Drawing Figures

But fig 9 shows in full find

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9/2003 10/018709

31 EAST - Default EAST Workspace [Flat Panel LANDSCAPE].wsp |

A screenshot of a software application window. The window has a title bar with the word 'EAX' at the top left. Below the title bar is a toolbar with various icons. The menu bar includes 'File', 'View', 'Edit', 'Tools', 'Window', and 'Help'. The main window contains a list of items under the heading 'Active'. The items are:

- L1: (14562) (205/50-333).CCLS.
- L2: (6313) (arc or arcs) near2 plasma
- L3: (3) (microarc or microarcs) near2 plasma
- L4: (6316) 12 or 13

Below this list is another list:

- L5: (36) 14 and 11

Underneath the lists are several status indicators: 'Failed', 'Saved', 'Favorites', 'Tagged (0)', 'UDC', 'Queue', and 'Trash'. On the right side of the window, there is a vertical scroll bar. At the top right, there are two checkboxes: 'Highlight all items today' and 'Drafts'.



File	New	Edit	Tools	Window	Help
<input type="checkbox"/> Drafts					
<input type="radio"/> Pending					
<input checked="" type="checkbox"/> Active					
L1: (14562) (205/50-333).CC1S.					
L2: (6313) (arc or arcs) near2 plasma					
L3: (3) (microarc or microarcs) near2 plasma					
L4: (6316) 12 or 13					
L5: (36) 14 and 11					
L6: (3949) ceramic adj coating					
L7: (59) 11 and 16					
<input type="checkbox"/> Failed					
<input type="checkbox"/> Saved					
<input type="checkbox"/> Favorites					
<input type="checkbox"/> Tagged (0)					
<input type="checkbox"/> UDC					
<input type="checkbox"/> Queue					
<input type="checkbox"/> Trash					

<input type="checkbox"/> Search	<input type="checkbox"/> List	<input type="checkbox"/> Browse	<input type="checkbox"/> Details	<input type="checkbox"/> Dates	<input type="checkbox"/> Events
<input type="checkbox"/> Highlight all the terms initially					
Do's					
USPA:IS-PPRIB					
Default operator: OR					
11 and 16					
<input type="checkbox"/> RSS feed					
<input type="checkbox"/> ISPR form					
<input type="checkbox"/> Image					
<input type="checkbox"/> Text					
<input type="checkbox"/> HTML					
Current OR: Current Ref: Retrieval C: Inventor S C 3 1					
Title	Document ID	Issue Date	Pages		
U	I	PR	P	Document	ID

<input type="checkbox"/> Details	<input type="checkbox"/> HTML
<input type="checkbox"/> No	
<input type="checkbox"/> Start	
<input type="checkbox"/> Stop	<input type="checkbox"/> Stop-Matched
<input type="checkbox"/> Stop-Nothing	<input type="checkbox"/> Stop-Partial
<input type="checkbox"/> Stop-Case	<input type="checkbox"/> Stop-Word
<input type="checkbox"/> Stop-Empty	<input type="checkbox"/> Stop-None
<input type="checkbox"/> New case file	
<input type="checkbox"/> Classops - No.	
<input type="checkbox"/> Application No.	
<input type="checkbox"/> New date file	
<input type="checkbox"/> 1345-03-0000	
NUM: 314 PM	
9/2003 10/018709	

Document ID	Patent No.	Kind Codes	Start Date
1 US 6610419 B1	US 6,290,834 B1		Sep. 18, 2001
2 US 6607787 B2			
3 US 6562223 B2			
4 US 6524710 B1			
5 US 6415644 B1			
6 US 6332937 B1			
7 US 6290834 B1			

**Brief Summary Text - Baux (8):**  
A desirable improved process would be one which has little or no ceramic re-melt or liquid flow on application of the laser to cut the ink/well patterns. Additionally, a desirable process would leave holes or cells having sharply defined patterns, having wells which are smooth and of the same texture as the surrounding area, to facilitate ink (and other material to be transferred) removal and cleanup as well as more precise patterns. Easier cleanup increases productivity and minimizes the chances of damage to the roll surface. And, a desirable process would be one which does not demonstrate a significant shortcoming of the thermal spray processes--the sometimes inadequate adherence of the coating to the roll substrate. This is an inherent difficulty with the thermal spray processes particularly for substrates, such as aluminum, having coefficients of thermal expansion considerably different from the ceramic coating.

**Brief Summary Text - Baux (9):**  
Further, it would be desirable to have a process wherein the laser-produced cell patterns are imparted to the roll surface prior to application of the ceramic coating rather than after, since application of the laser after coating incorporates all the above possible defects and shortcomings, and results in vertical surfaces in the cells which are different in composition from the horizontal surfaces. Coating after engraving is not feasible with sprayed ceramics.

**Brief Summary Text - Baux (16):**  
In another version of my invention, a hard wear resistant ceramic coating is formed on an incipient process roll having a blank metal surface by immersing it in an electrolytic bath comprising (deionized) water, an electrolytic agent comprising an alkali metal salt or hydroxide (preferably potassium hydroxide) at a concentration of 0.5-7 grams per liter, and, as a passivating agent, a colloidal suspension of sodium silicate in the form Na<sub>2</sub>SiO<sub>3</sub>.sub.2 (≈4gt; 2.55 by weight) at a concentration of 2.0-9.5 grams per liter while conducting through the bath a modified shaped-wave alternating electric current from a source of at least 250-800 volts through the surface of the printing (process) roll. The modified shaped-wave electric current rises from zero to its maximum height and falls to below 40% of its maximum height within less than quarter of a full alternating cycle, thereby causing dielectric breakdown and the formation of a compact ceramic film on the roll surface. I then remove the roll from the bath, grind or polish the formed ceramic coating to a suitably smooth finish, and engrave or emboss its surface, preferably by laser, to impose a three-dimensional pattern on the ceramic coating surface of the roll.

**Detailed Description Text - DENX (7):**  
The electrolytic treatment of the incipient liquid transfer roll will generally take about 30 to about 240 minutes to form a ceramic coating of 25 to 300 microns (0.001 to 0.012 inch) thick. A preferred thickness for the coating is 100 to 200 microns (0.004 to 0.012 inch) thick. Where the roll is aluminum, during the process cycle the substrate temperature is preferably maintained at less than 60 degree F. (140 degree C.). The incipient blank liquid transfer roll will preferably have an aluminum surface, but it may be made of aluminum, magnesium, titanium, zirconium, hafnium or alloys thereof.

**(12) United States Patent**

**(10) Patent No.:** US 6,290,834 B1  
**(45) Date of Patent:** Sep. 18, 2001

**(44) CERAMIC COATED LIQUID TRANSFER ROLLS AND METHODS OF MAKING THEM**

**(75) Inventor:** Thomas J. Pearsall, Summerfield, FL (US)

**(73) Assignee:** Ceramic Coatings Technologies, Inc., Palm City, FL (US)

**(1) Notice:** Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 0 days.

**(21) Appl. No.:** 09/548,095  
**(22) Filed:** Apr. 12, 2000

**(31) Int. Cl.:** C23D 5/34  
**(32) U.S. Cl.:** 205/205; 205/120; 205/220  
**(38) Field of Search:** 205/220, 102, 205/245

**(51) Primary Examiner—Kathy Goros  
Assistant Examiner—Thomas H Parsons  
(74) Attorney, Agent, or Firm—William L. Karter  
(77) ABSTRACT**

**(73) References Cited**

**U.S. PATENT DOCUMENTS**

3,832,293 8/1974 Hadzovoy et al. .... 204/56 R  
3,834,999 9/1974 Hadzovoy et al. .... 204/56 R  
3,891,516 6/1975 Chu .... 204/56 R  
3,956,088 5/1976 Hadzovoy et al. .... 204/56 R  
4,082,626 4/1978 Hadzovoy .... 204/56 R  
4,184,926 1/1980 Koch .... 204/52 R  
4,592,958 6/1986 Moyer et al. .... 422/432  
4,659,440 4/1987 Hadzovoy .... 204/53

**Liquid transfer rolls such as printing rolls are made by imposing a hard ceramic coating on an incipient liquid transfer roll in an electrolytic bath subjected to a modified shaped wave alternating current, which causes dielectric breakdown and the formation of a hard ceramic coating on the roll. The roll is later engraved to form liquid carrying reservoirs or cells on the surface of the roll, either before or after the ceramic coating is built on the roll.**

**ABSTRACT**

**(73) References Cited**

**U.S. PATENT DOCUMENTS**

3,832,293 8/1974 Hadzovoy et al. .... 204/56 R  
3,834,999 9/1974 Hadzovoy et al. .... 204/56 R  
3,891,516 6/1975 Chu .... 204/56 R  
3,956,088 5/1976 Hadzovoy et al. .... 204/56 R  
4,082,626 4/1978 Hadzovoy .... 204/56 R  
4,184,926 1/1980 Koch .... 204/52 R  
4,592,958 6/1986 Moyer et al. .... 422/432  
4,659,440 4/1987 Hadzovoy .... 204/53



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24 US 5354390 A	5	[REDACTED]							
25 US 5345551 A	17	[REDACTED]							
26 US 5293260 A	19	[REDACTED]							
27 US 5281326 A	3	[REDACTED]							
28 US 5217597 A	6	[REDACTED]							
29 US 5205921 A	4	[REDACTED]							
30 US 5147515 A	3	[REDACTED]							

DOCUMENT-IDENTIFIER:	US 5147515 A
TITLE:	Method for forming ceramic films by anode-spark discharge
RWIC	-----

Brief Summary Text - BSTR (35): Low outgassing properties, corrosion resistance and fastness properties can be imparted to an apparatus for manufacturing semiconductor devices by applying a ceramic film onto the shroud or the chamber of a reaction vessel of the apparatus according to the method of this invention. Moreover, if an aluminum or aluminum-clad copper conductors are provided with a ceramic coating, there can be obtained an electric wire coated with the ceramic layer having high dielectric breakdown voltage in addition to high flexibility and whose coated layer is hardly broken even if the layer has a flaw.

Current US Cross Reference Classification - CCXR (1) :  
205/320

Current US Cross Reference Classification - CCXR (2) :  
205/321

Current US Cross Reference Classification - CCXR (3) :  
205/322

Current US Cross Reference Classification - CCXR (4) :  
205/323

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DOCUMENT-ID	PATENT-NR.	SEARCH-NR.	US-PAT-NO.	KIND-CODES	SEARCH
26	US 5354390 A	5	US	USPA7	
25	US 5344551 A	17	US	USPA7	
26	US 5299260 A	19	US	USPA7	
27	US 5281326 A	3	US	USPA7	
28	US 5217597 A	6	US	USPA7	
29	US 5205921 A	4	US	USPA7	
30	US 5147515 A	3	US	USPA7	

DOCUMENT-IDENTIFIER: US 5147515 A  
TITLE: Method for forming ceramic films by anode-spark discharge

US-PAT-NO:  
RWIC

5147515

Brief Summary Text - BENTX (35):  
Low outgassing properties, corrosion resistance and fastness properties can be imparted to an apparatus for manufacturing semiconductor devices by applying a ceramic film onto the shroud or the chamber of a reaction vessel of the apparatus according to the method of this invention. Moreover, if an aluminum or aluminum cladded copper conductors is provided with a ceramic coating, there can be obtained an electric wire coated with the ceramic layer having high dielectric breakdown voltage in addition to high flexibility and whose coated layer is hardly broken even if the layer has a few.

RWIC

Low outgassing properties, corrosion resistance and fastness properties can be imparted to an apparatus for manufacturing semiconductor devices by applying a ceramic film onto the shroud or the chamber of a reaction vessel of the apparatus according to the method of this invention. Moreover, if an aluminum or aluminum cladded copper conductors is provided with a ceramic coating, there can be obtained an electric wire coated with the ceramic layer having high dielectric breakdown voltage in addition to high flexibility and whose coated layer is hardly broken even if the layer has a few.

Current US Cross Reference Classification - CCXR (1) :  
205/320

Current US Cross Reference Classification - CCXR (2) :  
205/321

Current US Cross Reference Classification - CCXR (3) :  
205/322

Current US Cross Reference Classification - CCXR (4) :  
205/323

3 Specific examples thereof include oxide type ceramic such as  $\text{Al}_2\text{O}_3$ ,  $\text{SiO}_2$ ,  $\text{Al}(\text{OH})_3$ ,  $\text{SiO}_2 \cdot 1\text{Al}_2\text{O}_3 \cdot 2\text{SiO}_2$ ,  $\text{TiO}_2$ ,  $\text{ZrO}_2$  and  $\text{CrO}_3$  and non-oxide type ceramics such as  $\text{SiC}$ ,  $\text{TiC}$ ,  $\text{TiN}$ ,  $\text{TiB}$ ,  $\text{ZrB}$ ,  $\text{BN}$ ,  $\text{WC}$ ,  $\text{WS}_2$  and  $\text{MoS}_2$ . These ceramic particles may be used alone or in combination.

The particle size of the ceramic particles desirably ranges from 0.03 to 100  $\mu\text{m}$ , in particular 0.03 to 20  $\mu\text{m}$ . That is, when the particle size thereof is increased, it is difficult to co-deposit the ceramic particles and if they are co-deposited the resulting film is non-uniform.

The amount of the fine particles of ceramic to be added to the electrolytic bath can be arbitrarily determined depending on the kind of the electrodes on which the fine particles are dispersed and the amount of the fine particles to be dispersed, but is in general up to 200 g/l and more preferably ranges from 5 to 100 g/l from the viewpoint of the efficiency of the deposition.

Examples of the fine particles used in the second aspect of the present invention are molybdenum disulfide, carbon, fluorinated graphite, tetrafluoroethylene or molybdenum nitride. Graphite is preferable as a carbon component used herein. These fine particles have self-lubricating properties, are hence often in the ceramic film during the spark discharge to thus give a film having good wear resistance.

In this embodiment, the fine ceramic particles used in the first aspect of the invention can be used together with the fine particles having self-lubricating properties. The particle size of the fine particles having self-lubricating properties desirably ranges from 0.01 to 100  $\mu\text{m}$  and preferably 0.03 to 20  $\mu\text{m}$ . That is, when the particle size thereof is increased, it is difficult to co-deposit the ceramic particles and if they are co-deposited the resulting film is non-uniform.

The amount of the fine particles having self-lubricating properties to be added to the electrolytic bath can be arbitrarily determined depending on the kinds of the electrodes on which the fine particles are dispersed and the amount of the fine particles to be dispersed, but is in general up to 200 g/l and more preferably ranges from 5 to 100 g/l from the viewpoint of the efficiency of the deposition.

In the first and second aspects of the present invention, examples of the metal substrates on which a ceramic film can be formed by the spark discharge technique include those made from aluminum and alloys thereof, zirconium, titanium, niobium, magnesium and alloys thereof.

When a film is formed on metal substrate by spark discharge, the substrate must not be subjected to a particular pretreatment, but it is desirable to sufficiently clean the surface of the substrate through degreasing, washing with an acid or the like.

An insoluble electrode is used as a cathode and the cathode may be formed from, for instance, iron, stainless steel, nickel or the like.

In the method of the present invention, the spark

4 When fine particles having poor dispersion properties are employed, there may be used a dispersant, for instance, a surfactant such as cationic, non-ionic or anionic ones for obtaining a good dispersion.

The temperature of the electrolytic bath during the spark discharge in general ranges from 5° to 90° C, and preferably 15° to 60° C. This is because, if it is too low, the film-forming velocity by the spark discharge is low, while if it is too high, it is liable to form a non-uniform film.

In addition, if the current density used is too low, the fine particles are hardly deposited, while if it is too high, the film having a low particle density or a coarse film is formed at high current portions. Therefore, the current density preferably ranges from 0.2 to 20 A/dm<sup>2</sup>, more preferably 1 to 5 A/dm<sup>2</sup>.

The output from a power supply may be a direct current having any wave form, but preferably those having pulse shape (rectangular wave form), saw-tooth-like or half-wave form.

The spark discharge-initiating voltage varies depending on various factors such as the wave form of the output current from the dc power supply, the concentration of the silicate and that of the oxyacid salt and the temperature of the bath, but it desirably ranges from 50 to 200 V. Moreover, the voltage observed during the film formation is increased, at the spark discharge proceeds and the final voltage sometimes exceeds 1,000 V.

The electrolysis time varies depending on the desired thickness of the resulting film. However, if the resulting film is thin, the film does not show the quality peculiar thereto. Therefore, the electrolysis must be performed for at least 5 minutes. In general, practically acceptable film having a thickness, for instance, ranging from 2 to 50  $\mu\text{m}$  can be obtained if the electrolysis is performed for 10 to 60 minutes.

According to the first aspect of the present invention, there can effectively be prepared metallic materials having ceramic film having high insulating properties, high hardness and a variety of color tones.

Low outgassing properties, corrosion resistance and flame properties can be imparted to an apparatus for manufacturing semiconductor devices by applying a ceramic film onto the shroud or the chamber of a reaction vessel of the apparatus according to the method of this invention. Moreover, if an aluminum or aluminum cladded copper conductors is provided with an electric wire coated with a ceramic coating, there can be obtained an electric wire having high dielectric breakdown voltage in addition to high flexibility and whose coated layer is hardly broken even if the layer has a few.

According to the first aspect of this invention, the color tone of the resulting film is rather white depending on the kinds of the fine particles used and, therefore, the method can also be useful as a whitening treatment for aluminum construction materials.

If a ceramic film is applied onto a container for cosmetics, there can be obtained an electric wire coated with the ceramic layer having high dielectric breakdown voltage in addition to high flexibility and whose coated layer is hardly broken even if the layer has a few.

The second aspect of the present invention makes it possible to effectively produce metallic materials having

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**EAST - Individual EAST WorkSpace [Flat Panel LANDSCAPE.wsp.1]**

File New Edit Tools Window Help

Drafts  
 Pending  
 Active  
 L1: (14562) (205/50-333).CCJS.  
 L2: (6313) (arc or arcs) near2 plasma  
 L3: (3) (microarc or microarcs) near2 plasma  
 L4: (6316) 12 or 13  
 LS: (36) 14 and 11  
 L6: (3949) ceramic adj coating  
 L7: (59) 11 and 16  
 L8: (15154) arc same discharge  
 L9: (32) 11 and 16  
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US-PAT-NO:	3385662
DOCUMENT-IDENTIFIER:	US 3385662 A
TITLE:	Method of producing oxide ceramic layers on barrier layer-forming metals and articles produced by the method

**Brief Summary Text - BSNX (6):**  
Because of the pattern of the current density/potential curves for the anodic spark discharge, three distinct portions can be distinguished. i.e. the Parady portion, the spark discharge portion and the arc-discharge portion, see P. Kurze mentioned above.

Current US Original Classification - CCOR (1):  
205/316

Current US Cross Reference Classification - CCXR (1):  
205/321

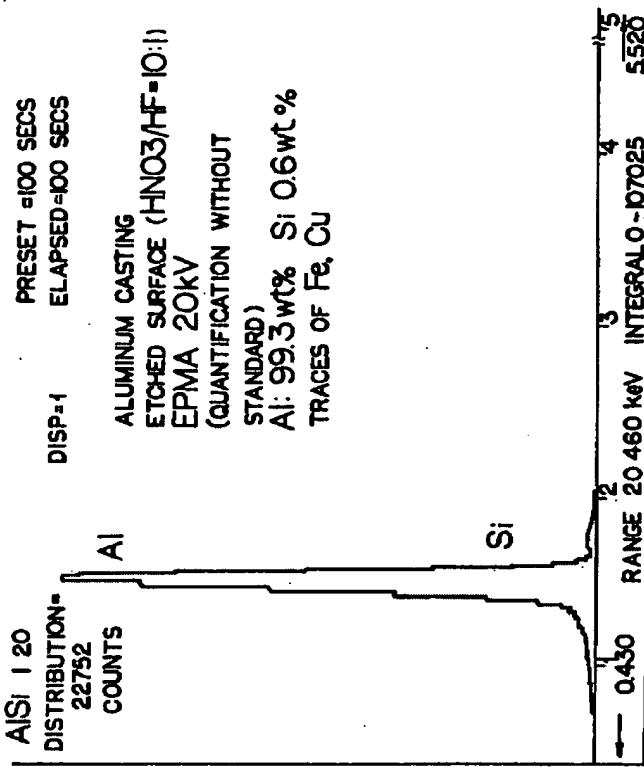
Current US Cross Reference Classification - CCXR (2):  
205/322

Current US Cross Reference Classification - CCXR (4):

United States Patent	[19]	[11] Patent Number:	5,385,662
Kurze et al.	[45] Date of Patent:	Jan. 31, 1995	
[54] METHOD OF PRODUCING OXIDE CERAMIC LAYERS ON BARIER LAYER-FORMING METALS AND ARTICLES PRODUCED BY THE METHOD			
[75] Inventor: Peter Kurze, Dorn-Buerkle, Koenig-Hans-Joergen Kleste, Dlicca, all of Germany		4,859,719 9/1990 Kurze et al. ....	205/324
[73] Assignee: Electro Chemical Engineering GmbH, Zug, Switzerland		4,894,651 2/1990 Mohamed ....	205/329
[21] Appl. No.: 962,092	[22] Filed: Nov. 25, 1992		FOREIGN PATENT DOCUMENTS
[30] Foreign Application Priority Data			28005 4/1991 German Dem. Rep. ....
Nov. 27, 1991 [DE] Germany ..... 4138006			
[51] Int. Cl. 4	C10D 9/06		
[52] U.S. Cl. 205/316, 205/321;			
[58] Field of Search ..... 205/322; 205/323; 205/324			
[56] References Cited	205/324, 329, 316, 331;		
	205/321, 322, 204/178		
[56] U.S. PATENT DOCUMENTS			
3,862,892 1/1973 Lammerzahlger et al. ....	205/324		
4,461,043 11/1994 Ball et al. ....	205/324		
OTHER PUBLICATIONS			
Van et al. "Mechanism of Anodic Spat Deposition" in American Ceramic Society Bulletin (Jan., 1977) vol. 56, No. 6, pp. 563-566.			
Primary Examiner—John Nitschke Assistant Examiner—Brendan MacCormac, Agent or Firm—Cohen, Puntak, Lieberman & Pavans			
ABSTRACT			
[57] A method of producing oxide ceramic layers on Al, Mg, Ti, Ta, Zr, Nb, Hf, Si, W, Mo, V, Bi or their alloys by a plasma-chemical anodic oxidation in a chloride-free electrolyte bath having a pH value of 2 to 8 and a constant bath temperature of -30° to +15° C. A current density of at least 1 A/dm <sup>2</sup> is maintained constant in the electrolytic bath until the voltage reaches a predetermined end value.			
7 Claims, No Drawings			

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316 winter current constant



**Brief Summary Text - BTRX (5):**  
It is known to produce high-adhesion, dense and thick dispersion films on metals, especially on iron and iron work materials, by means of anodic arc-discharge or conventional thermal treatment by deposition from dispersion avacuums (DD-PS 15130).

Current US Cross Reference Classification - CCXR (1):  
205332

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10/01/18709  
14517 P11Q01  
Hull - 1000-0000

US-PAT-NO: 4869789  
DOCUMENT-IDENTIFIER: US 4869789 A  
TITLE: Method for the preparation of decorative coating on metals

**Brief Summary Text - B9M (15):**  
 It has been found that voltages which are associated with the arc-discharge region in the current-voltage characteristic of the electrolyte-metal pairing, and which usually cause destruction of the coating, do yield an all-round homogeneous coating in connection with nucleation on  $n = 200$  Hz.

Current US Original Classification - CCOR (1):  
205/108

Current US Cross-Border Classification = CCXB (1):

Current US Cross Reference Classification - CCXR (2):

W215 p112 35-35n<sup>172</sup>

<b>United States Patent</b>	[19]	[11] Patent Number:	4,869,789
Kurze et al.	[54]	[55] Date of Patent	Sep. 26, 1989
<b>METHOD FOR THE PREPARATION OF DECORATIVE COATING ON METALS</b>			
[73] Inventors: Peter Kurze, Oberlichtenau; Waldemar Kryemann; Mario Berger, both of Karl-Marx-Stadt; Klaus Pfeilwisch, Tauta; Loesches Schlechtnabach, Linbach-Oberfrohna; Thomas Schwerz, Karl-Marx-Stadt; Karl-Hermann Hartmann, Güntersberge, all of German Democratic Rep.	[27] U.S. Cl. ....	[35] U.S. Cl. ....	204/148 204/56.1, 58
[73] Assignee: Technische Universität Karl-Marx-Stadt, Karl-Marx-Stadt, German Democratic Rep.	[36] U.S. PATENT DOCUMENTS	[36] References Cited	
[21] Appl. No.: 151,363	4,141,612 3/1979 Takemoto		
[22] Filed: Feb. 2, 1988	Primary Examiner—T. M. Turilliello		
[30] Foreign Application Priority Data	Attorney, Agent or Firm—Jordan and Hamburg		
Feb. 2, 1987 [DD] German Democratic Rep. — 229618			
Feb. 1, 1987 [DD] German Democratic Rep. — 229619			
[31] Int. Cl. .... C25D 11/04 C25D 11/04	9 Claims, No Drawings		

9/2003 10/018709

A screenshot of a search interface, likely from a software like EndNote or a similar bibliographic manager. The top menu bar includes 'File', 'Edit', 'View', 'End', 'Tools', 'Window', and 'Help'. A toolbar below has icons for 'New', 'Open', 'Save', 'Print', 'Copy', 'Paste', 'Find', 'Replace', 'Delete', 'Import', 'Export', 'Search', 'Browse', 'Queue', and 'Dear'. The main window shows a list of search results under the heading 'Active'. Each result is a row with a checkbox, a small icon, and three numbered labels (L1, L2, L3) followed by the citation details. The first result is: L1: (14562) (205/50-333).CCLS. L2: (6313) (arc or arcs) near2 plasma L3: (3) (microarc or microarcs) near2 plasma. Below the list are buttons for 'Search', 'Browse', 'Queue', and 'Dear'. On the right, there are buttons for 'Print', 'Copy', 'Paste', 'Delete', 'Import', 'Export', and 'Search'. A vertical sidebar on the right contains buttons for 'Search', 'Browse', 'Queue', and 'Dear'. At the bottom, there are buttons for 'Failed', 'Saved', 'Favorites', 'Tagged (0)', 'UDC', 'Queue', and 'Trash'. A status bar at the bottom right shows '11 and 112'.

Document- Identifier:	US 6365028 B1
TITLE:	Method for producing hard protection coatings on articles made of aluminum alloys

US-PAT-NO:

6365028

Bl

Brief Summary Text - BSMX (9):

A method is known for applying solid corrosion-resistant coatings to items made of aluminum and its alloys (U.S. Pat. No. 5,275,713) in an aqueous electrolyte solution containing an alkaline fluoride, alkaline metal hydroxide and a metal oxide (for example, molybdenum oxide). The solution has a pH of 11-2-11.8. A positive potential is delivered to the item from a direct or pulsed current source. For the first 1-60 s the voltage is raised to 240-600 V, and over the next 1-20 minutes (depending on the required coating thickness) it is steadily increased to 380-420 V. The introduction of hydrogen peroxide as an oxygen accumulator into the electrolyte helps to raise the rate of increase of the oxide coating and its hardness through intensification of oxide coating of the metal in the spark discharge zone.

Brief Summary Text - BSMX (17):

The oxide coating time may not be shortened by raising the electrical parameters of the electrolysis, for example the current density (above 30 A/dm.<sup>2</sup>, sup.2), because of a deterioration in the quality of the coating and a steep rise in the energy consumption of the process. The time of transition from the anodising stage to the spark discharge stage, however, depends on the initial current density.

Current US Original Classification - CCOR (1):

205/102

Current US Cross Reference Classification - CCXR (1):

205/103

Current US Cross Reference Classification - CCXR (2):

205/106

Current US Cross Reference Classification - CCXR (3):

205/323

Document:	ID	V	Pages	1	2	3	4	U	S	C	P	Kind Codes	Sort
1	US 6527118 B1		4	□	□	□	□	□	□	□	□	USPAT	
2	US 6487969 B2		6	□	□	□	□	□	□	□	□	USPAT	
3	US 6365028 B1		7	□	□	□	□	□	□	□	□	USPAT	
4	US 6365028 B1		8	□	□	□	□	□	□	□	□	USPAT	
5	US 6358391 B1		7	□	□	□	□	□	□	□	□	USPAT	
6	US 5723038 A		4	□	□	□	□	□	□	□	□	USPAT	
7	US 570866 A		9	□	□	□	□	□	□	□	□	USPAT	

## (12) United States Patent

(10) Patent No.: US 6,365,028 B1

(45) Date of Patent: Apr. 2, 2002

## (54) METHOD FOR PRODUCING HARD PROTECTION COATINGS ON ARTICLES MADE OF ALUMINUM ALLOYS

(54) FOREIGN PATENT DOCUMENTS

RU	1200591	411989
RU	1713990	211992
RU	9402396	101986
RU	2070622	121986
WO	WO9518250	701995

(73) Inventor: Aleksandr Sergeevich Shaturov, Moscow (RU)

(73) Assignee: Isle Coat Limited (GB)

(57) Cited by Examiner

Primary Examiner—Kathryn George  
Assistant Examiner—Weiley A. Nicolas  
(74) Attorney, Agent, or Firm—Sheridan Rose P.C.

## ABSTRACT

This invention relates to the sphere of plasma electrolytic coating of aluminium alloys. The method incorporates anodic-anatase oxide coating in an alkaline electrolyte at a temperature of 15-50° C., using 50-60 Hz frequency alternating current. In the initial stage of the process oxide coating is carried on for 5-90 seconds at a current density of 160-180 A/dm<sup>2</sup>, then the current density is dropped to 3-30 A/dm<sup>2</sup> and the process is continued in a regimen of spontaneous diminution of power demand without on-line adjustment of the regimen until the set coating thickness is achieved. The alkaline electrolyte used is an aqueous solution of alkaline metal hydroxide at 1-5 g/l, an alkaline metal silicate at 2-5 g/l, an alkaline metal pyrophosphate at 2-20 g/l and peroxide compounds at 2-7 g/l (in terms of H<sub>2</sub>O<sub>2</sub>—30%). The method enables the protective properties of ceramic oxide coatings to be enhanced through an increase in the micro-hardness, density and strength of adhesion to the substrate without any additional energy outlay or heat required.

## (\*) Notice: Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 0 days.

(57)

(21) Appl. No.: 09/584,494

(22) PCT Filed: Dec. 17, 1997

(87) PCT Pub. No.: WO95/21303

(PCT Pub. Date: Jun. 24, 1999

(86) PCT No.: 9371 Date: Jun. 14, 2000

(87) Int. Cl. 2: C24D 9/18

(51) Int. Cl. 7: C24D 9/18

(52) U.S. Cl. 205/102, 205/103, 205/106, 205/323, 205/326

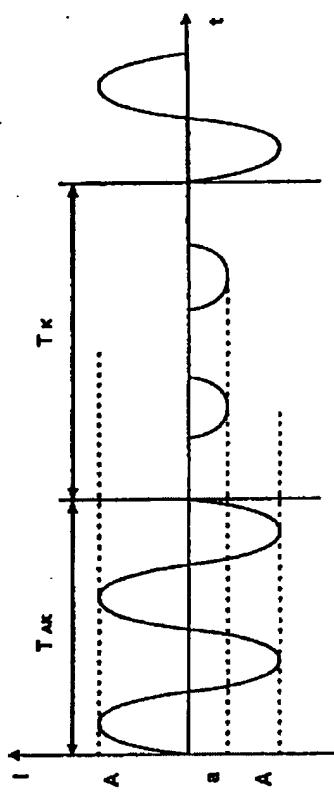
(58) Field of Search: 205/102, 106, 205/107, 108, 109, 323, 324, 325, 326, 204/DIG. 9

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## 4 Claims, 1 Drawing Sheet



9/2003 10/018709

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